



EVG NIL Technology Day

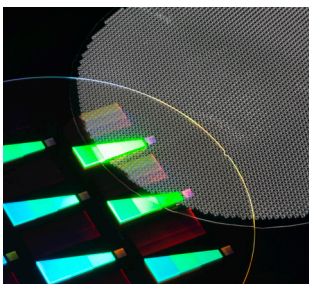
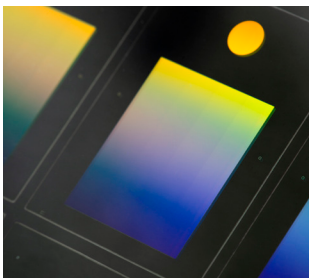
France
April 24, 2024

Schedule

April 24, 2024
10:00 - 16:15 hrs
EVG Technology Day

Location

Mercure Grenoble Meylan,
34 av de Verdun,
38240 Meylan,
France



Register

For more information
and to register for free:

www.EVGroup.com/events

Latest Trends in AR/VR, Silicon Photonics, Automotive and Meta Lenses

Agenda

09:30	Registration
10:00	Welcome and Introduction Otto Bobenstetter, Regional Sales Manager Europe, EV Group (EVG)
10:15	NIL Market Update Thomas Achleitner, Business Development Manager, EV Group (EVG)
10:45	NIL mastering using advanced manufacturing imaging technology Brid Connolly, Strategic Applications Manager, TOPPAN Photomasks
11:15	NIL Materials Dr. Alexander Plucinski, CTO Micro Resist Technology (MRT)
11:45	NIL Process Capabilities Thomas Achleitner, Business Development Manager, EV Group (EVG)
12:15	Lunch
13:15	Enhancing Augmented Reality: Flexible Production of Slanted Surface Relief Gratings (SRG) with Ion Beam Technology Dr. Mandy Göring, R&D Engineer, scia Systems
13:45	3D pattern replication for optical applications Api Warsono, R&D Lithography Process Engineer, LETI
14:15	NIL Equipment Portfolio Dr. Martin Eibelhuber, Product Manager, EV Group (EVG)
14:45	Coffee Break
15:05	Metaoptics produced by Nanoimprint Lithography and dry etching Brian Bilenberg, Founder and Executive VP, NILT
15:35	NIL Latest Developments Dr. Martin Eibelhuber, Team Leader Product Management, EV Group (EVG)
16:05	Summary and Wrap-Up Réunion

